Table 6: Cross-material comparison of confinement-induced band gap shifts in nanostructures.

Material	Bulk Band Gap	Effect of Quantum Confinement	Tunable Range	Special Notes
Si	1.1 eV (indirect) [13]	Increases, enhances optical transitions [14]	$\sim 1.1 \rightarrow 2 \text{ eV}$ [15]	Useful for Si-based photonics
Ge	0.66 eV (indirect) [13]	Can approach direct gap, widens to $\sim 2 \text{ eV } [15]$	$\begin{array}{c} 0.66 \rightarrow \sim 2 \text{ eV} \\ [3] \end{array}$	Becomes optically active
ZnO	3.37 eV (direct)	Band gap widens with diameter decrease [18]	$\sim 0.8 \rightarrow 2.15$ eV (nanostructures) [15]	Always semiconducting, good for UV devices
GaN	3.4 eV (direct) [18]	Widens significantly, up to $\sim 5 \text{ eV } [16]$	$3.4 \rightarrow \sim 5 \text{ eV}$	Excellent for high-power UV optoelectronics [11]